

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Youhei SAKAI, et al.

Serial No: 10/597,514

Confirmation No.: 2199

Filed: July 27, 2006

For: Mold, Method of Forming the Same, and
Method of Producing Polycrystalline Silicon
Substrate Using the Mold

Art Unit: 1791

Examiner: S. M. Malekzadeh

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

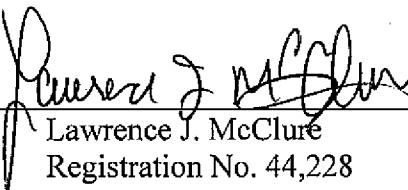
In response to the Restriction Requirement dated March 13, 2009, Applicant elects for prosecution, Group I, Claims 18-34 and 36 drawn to a mold apparatus formed by combining a bottom surface member and a plurality of lateral surfaces.

If there are any fees due in connection with the filing of this response, please charge the fees to our Deposit Account No. 50-1314.

Respectfully submitted,

HOGAN & HARTSON L.L.P.

Date: April 13, 2009

By: 
Lawrence J. McClure
Registration No. 44,228
Attorney for Applicants

1999 Avenue of the Stars, Suite 1400
Los Angeles, California 90067
Telephone: (310) 785-4600
Facsimile: (310) 785-4601